

UC Irvine

UC Irvine Previously Published Works

Title

Electronic transport in Ce₃Bi₄Pt₃: evidence for a temperature-dependent hybridization gap

Permalink

<https://escholarship.org/uc/item/3m45s4qc>

Journal

Physica B Condensed Matter, 199(C)

ISSN

0921-4526

Authors

Hundley, MF
Thompson, JD
Canfield, PC
[et al.](#)

Publication Date

1994-04-01

DOI

10.1016/0921-4526(94)91864-3

Copyright Information

This work is made available under the terms of a Creative Commons Attribution License, available at <https://creativecommons.org/licenses/by/4.0/>

Peer reviewed



Electronic transport in $\text{Ce}_3\text{Bi}_4\text{Pt}_3$: evidence for a temperature-dependent hybridization gap

M.F. Hundley*, J.D. Thompson, P.C. Canfield¹, Z. Fisk

Los Alamos National Laboratory, Los Alamos, NM 87545, USA

Abstract

We present an analysis of transport data from $\text{Ce}_3\text{Bi}_4\text{Pt}_3$ to determine the energy gap temperature dependence $E_g(T)$. $E_g(T)$ is a decreasing function of temperature. This result is consistent with the gap being a product of many-body correlations in which $E_g(T)$ is scaled by the Kondo energy scale T_K .

$\text{Ce}_3\text{Bi}_4\text{Pt}_3$ is a narrow-gap Kondo insulator [1] in which the energy gap results from band hybridization driven by many-body effects. Mean-field treatments [2, 3] of the Anderson lattice Hamiltonian suggest that the gap should be a decreasing function of temperature scaled by T_K . In this note we present the results of an analysis of the energy gap $E_g(T)$ as determined from the resistivity ρ and thermoelectric power S of $\text{Ce}_3\text{Bi}_4\text{Pt}_3$. The analysis indicates that E_g is strongly temperature-dependent above 50 K, dropping close to zero at 300 K. As the gap shrinks above 100 K, single-impurity Kondo (SIK) scattering becomes evident in the resistivity. Upon comparing $E_g(T)$ with bulk modulus B and pressure-dependent $E_g(P)$ data, a single energy scale (T_K) appears to govern both $E_g(T)$ and the thermal expansion β .

The ρ and S of $\text{Ce}_3\text{Bi}_4\text{Pt}_3$ are plotted in Fig. 1. With a temperature-independent gap and electron-phonon (EP) scattering, both data sets would appear as straight lines in Fig. 1; in both cases, the slope, and therefore E_g , drops with increasing temperature. Some curvature is

also expected because this material is an extremely degenerate semiconductor (i.e., $E_g \sim k_B T$). Therefore, a careful quantitative analysis employing degenerate semiconductor statistics [4] is required to determine $E_g(T)$. We model the system as involving two wide parabolic bands separated by $E_g(T)$; this is a reasonable assumption for the lower and upper hybridized bands away from the Brillouin zone edge. In addition, we assume that EP scattering predominates. The results of a degenerate semiconductor analysis with these assumptions are presented in Fig. 2, along with a mean-field prediction [3]. $E_g(T)$ is a decreasing function of temperature, as expected for a gap produced by many-body effects. Further, the gaps determined from ρ and S are equivalent; this is an indication that the assumption concerning scattering is valid since ρ and S are affected by EP scattering in fundamentally different ways. Above 100 K the uncertainty in the gap determined from S increases, but it is still consistent with a shrinking gap. Despite considerable scatter in E_g above 100 K as determined from ρ , the gap appears to saturate to $E_g = 70$ K. This is an artifact of the assumption that only EP scattering is present. It suggests that SIK scattering develops as the gap shrinks with increasing temperature.

* Corresponding author.

¹ Present address: Ames Laboratory, Iowa State University, Ames, IA 50011.

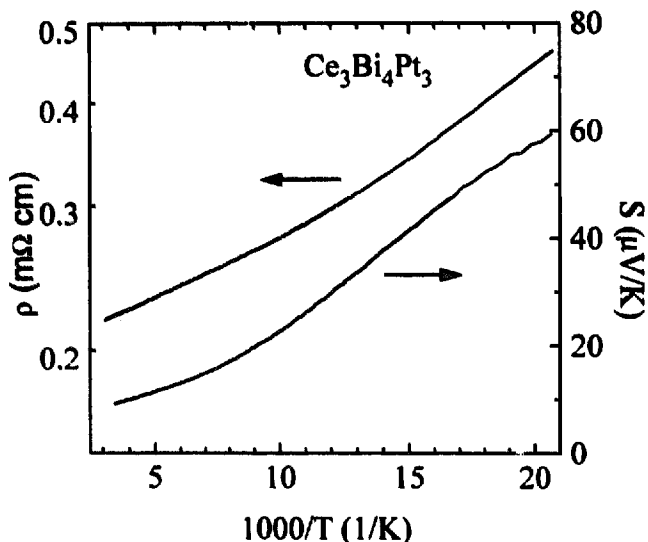


Fig. 1. $\log_{10} \rho$ and S plotted as a function of $1/T$. In both cases the slope drops with increasing temperature, indicating that E_g is a decreasing function of temperature.

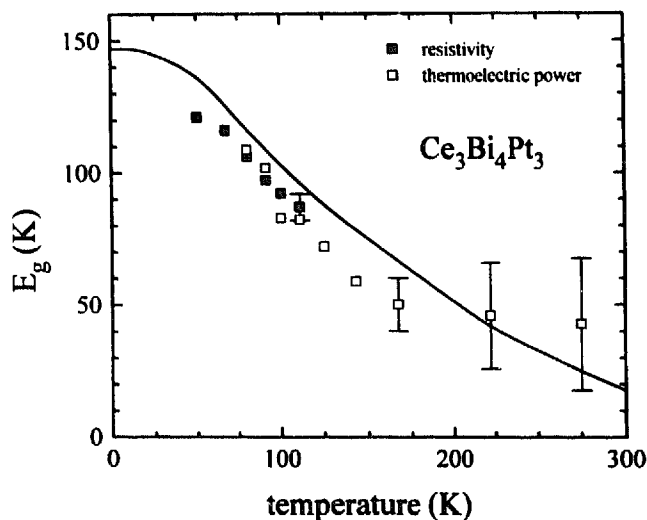


Fig. 2. $E_g(T)$ as determined from analyses of ρ (filled squares) and S data (open squares). The solid line is a mean-field prediction [3] based on the Anderson lattice Hamiltonian.

SIK scattering involves electrons in an Abrikosov–Suhl resonance of width T_K near E_F . With a wide gap centered at E_F no scattering occurs. As the temperature is raised and E_g falls well below T_K , a partially gapped resonance will develop; therefore, SIK scattering should become evident as the temperature is raised. Preliminary high-temperature ρ measurements suggest that the gap disappears above 350 K and $\text{Ce}_3\text{Bi}_4\text{Pt}_3$ acts as an SIK metal.

The volume thermal expansion β of $\text{Ce}_3\text{Bi}_4\text{Pt}_3$ also displays a temperature dependence dominated by many-body effects [5]. If the temperature dependence of β and E_g result from hybridization driven by correlations they must be quantitatively interconnected. We can ensure that the gap scales with the thermal expansion by comparing $E_g(T)$ with bulk modulus and pressure-dependent gap, $E_g(P)$ measurements. With a bulk modulus $B \approx 900$ kbar, the thermal contraction at 4 K relative to 300 K is equivalent to 14.4 kbar pressure [5]. With $\partial E_g / \partial P \approx +11 \pm 6$ K/kbar [1], the expected increase upon cooling from 300 K to 4 K is $\Delta E_g = +160 \pm 90$ K; despite the crude nature of this calculation it is in good qualitative agreement with the data in Fig. 2. This quantitative consistence is a manifestation of the fact that all physical quantities controlled by many-body interactions in $\text{Ce}_3\text{Bi}_4\text{Pt}_3$ are fundamentally interrelated and their respective temperature dependencies are scaled by the Kondo energy scale T_K .

We thank S.E. Brown and C. Sanchez-Castro for fruitful discussions. This research was performed under the auspices of the US Department of Energy.

References

- [1] J.D. Thompson et al., in: *Transport and Thermal Properties of f-Electron Systems*, eds. H. Fujii, T. Fujita and G. Oomi (Plenum, New York, 1993) p. 35.
- [2] P.S. Riseborough, *Phys. Rev. B* 45 (1992) 13984.
- [3] C. Sanchez-Castro et al., *Phys. Rev. B* 47 (1993) 6879.
- [4] D.R. Lovett, *Semimetals and Narrow-Band Gap Semiconductors* (Pion, London, 1977) p. 72.
- [5] G.H. Kwei et al., *Phys. Rev. B* 46 (1992) 8067.